Electronic Pate	nt App	lication Fee	Transm	ittal			
Application Number:	103	10720097					
Filing Date:	25-	25-Nov-2003					
Title of Invention:		Process for forming resist pattern, semiconductor device and fabrication thereof					
First Named Inventor/Applicant Name:	Min	Miwa Kozawa					
Filer:	Kei	Kenneth H. Salen./Anita Plummer					
Attorney Docket Number:	03:	032132					
Filed as Large Entity	•						
Utility under 35 USC 111(a) Filing Fees							
Description		Fee Code	Quantity	Amount	Sub-Total in USD(\$)		
Basic Filing:							
Pages:							
Claims:							
Miscellaneous-Filing:							
Petition:							
Patent-Appeals-and-Interference:							
Post-Allowance-and-Post-Issuance:							
Extension-of-Time:							
Extension - 1 month with \$0 paid		1251	1	130	130		

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)			
Miscellaneous:							
Request for continued examination	1801	1	810	810			
	Tot	940					